

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No.: 10/796,170 Confirmation No.: 3493
Applicant(s): Ogihara, et al.
Filed: March 9, 2004
Art Unit: 1711
Examiner: Irina Sopijia Zemel
Title: COMPOSITION FOR FORMING POROUS FILM, POROUS FILM AND
METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR FILM,
AND SEMICONDUCTOR DEVICE

Docket No.: 035576/275605

Customer No.: 00826

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE UNDER 37 C.F.R. § 1.121

Sir:

In response to the Office Action dated June 20, 2006, please reconsider the above-identified application based on the following:

Remarks/Arguments begin on page 2 of this paper.